Curriculum Vitae

Personal Information

Name: Symeon I. Tsintzos

Nationality: Greek

Date of birth: 20 November 1979 Place of birth: Athens, Greece

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2) Foundation for Research & Technology Hellas (FORTH), Inst. of Electronic Structure

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Positions

• 01/07/2018- Today: Scientist Engineer

Eulambia Advanced Techonologies LTD.

• 1/07/2018-Today: External Associate Researcher

Foundation for Research & Technology Hellas (FORTH), Inst. of Electronic Structure and Laser (IESL), Microelectronics Research Group (MRG)

• 1/12/2016-30/06/2018: Postdoctoral Research Fellow

Foundation for Research & Technology Hellas (FORTH), Inst. of Electronic Structure and Laser (IESL), Microelectronics Research Group (MRG)

• 1/10/2015-30/11/2016: Postdoctoral Research Fellow

Crete Center for Quantum Complexity and Nanotechnology, University of Crete, Physics Department

01/01/2014-30/09/2015: Postdoctoral Research Fellow

Foundation for Research & Technology Hellas (FORTH), Inst. of Electronic Structure and Laser (IESL), Microelectronics Research Group (MRG)

- 10/06/14-10/10/14: Postdoctoral Research Fellow at Ioffe Physical Technical Institute, Saint Petersburg, St. Petersburg, Russia
- 20/06/13-20/10/13: Postdoctoral Research Fellow at Ioffe Physical Technical Institute, Saint Petersburg, St. Petersburg, Russia
- 25/05/12-25/09/12: Postdoctoral Research Fellow at Ioffe Physical Technical Institute, Saint Petersburg, St. Petersburg, Russia
- 01/12/2012-31/12/2013: Postdoctoral Research Fellow

University of Crete, Department of Materials Science and Technology.

- 12/06/2011-20/12/2011: Postdoctoral Research Fellow at Nano-photonics Group, Cavendish Laboratory, Cambridge.
- 10/01/2011-30/11/2012: Postdoctoral Research Fellow

Foundation for Research & Technology Hellas (FORTH), Inst. of Electronic Structure and Laser (IESL), Microelectronics Research Group (MRG)

Education

2006-2010	PhD in Materials Science and Technology, University of Crete, Greece <u>Title:</u> "Polariton Light Emitting Devices"
2003-2006	MSc in Microelectronics/Optoelectronics with specialization in semiconductor lasers, Physics Department, University of Crete, Greece. <u>Dissertation:</u> "Electric field tunable Vertical Cavity Surface Emitting Laser"
1998-2003	BSc in Physics, University of Patras, Greece. <u>Diploma Thesis: "Fiber Raman lasers and amplifiers"</u>

Participation in Research Projects

- 1. FP7-NANOTEC (GA no 288531)
- 2. FP7-SMARTPOWER (GA no 288801)
- 3. FP7-POLAFLOW (GA no 308136)
- 4. NFFA-EUROPE (GA no 654360)
- 5. FP7-REGPOT (Project no 316165)
- 6. ARISTEIA, APOLLO (no 1978)
- 7. THALIS (MIS 377292)
- 8. SNF-ARCHERS

Research Grants

1. Greek GSRT EΔBM 34, Young Investigator Support Grant "Analog Polariton Simulator". (56,350 €)

Honors-Awards

- 1. Manasaki Scholarship for postgraduate students (2008), Department of Materials Science and Technology, Univ. of Crete
- Stavros Niarchos Foundation Scholarship within the framework of the project ARCHERS ("Advancing Young Researchers' Human Capital in Cutting Edge Technologies in the Preservation of Cultural Heritage and the Tackling of Societal Challenges", 2017),

Scientific Interests

- 1. Novel polaritonic devices (LEDs, Lasers, Transistors, Switches, single photon emitters, polariton optical circuits).
- 2. Hybrid semiconductor-organic polariton LEDs.
- 3. Semiconductor optoelectronic devices (Edge emitting lasers, Vertical cavity surface emitting lasers, self-assembled InAs quantum dots single photon emitters).
- 4. Classical and quantum photonic cryptographic schemes and all optical processing.

Research and Professional Experience

- Semiconductor (III-V Arsenides) lithography clean room techniques.
- Device and Photolithographic mask design.
- Processing of III-V semiconductors and polymers (PMMA, PMGI)
- Packaging-bonding of semiconductor/organic devices.
- Electrical characterization.
- Optical characterization techniques at room and cryogenic temperatures.
 (Photoluminescence, Time resolved Photoluminescence, Reflectivity, Transmittance, k-space and real space imaging)
- Mentoring ten students (5 PhD, 3 master thesis, 2 diploma thesis)
- Programming Languages: Mathematica, Matlab, OriginLab.
- Scientific Document Preparation: Microsoft office, OriginLab, LaTex.